

# Radiation damage caused by neutron capture in boron doped silicon pixel sensors

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27.3.2017

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# What is the task and why MAPS can do it?

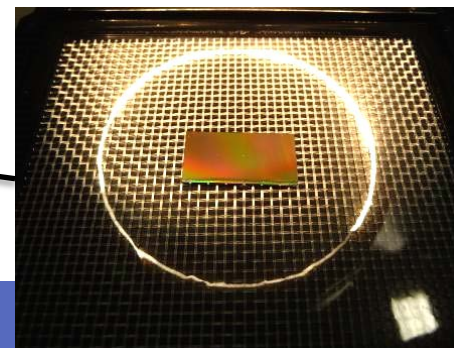
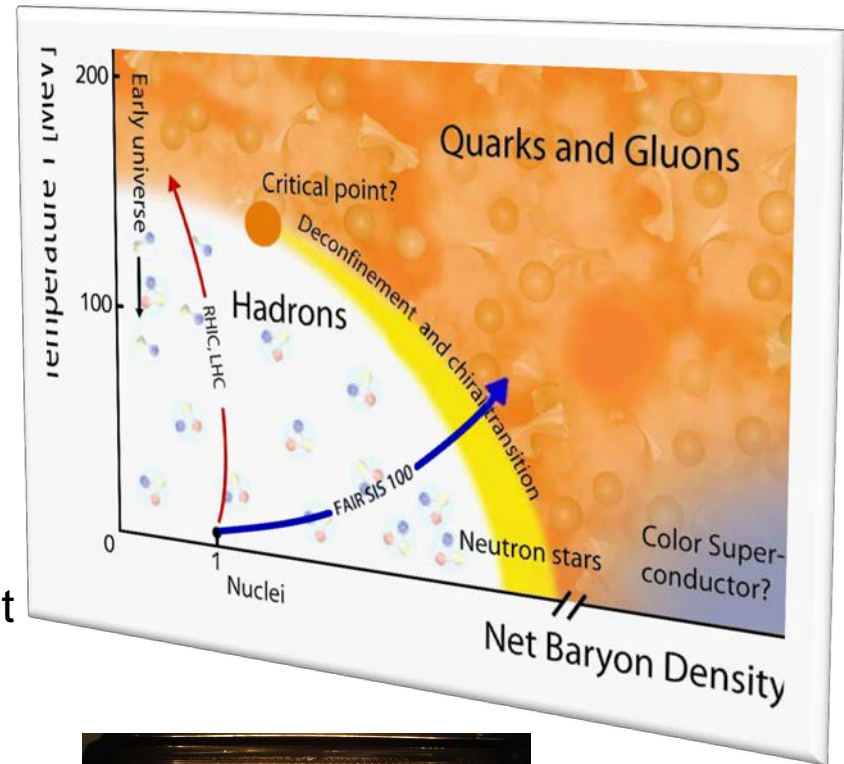
Study matter at extreme conditions by reconstructing secondary vertices of dileptons and open charm particle

Need:

- Good spatial resolution
- High granularity
- Vacuum compatible design
- Radiation tolerant
- Low material budget

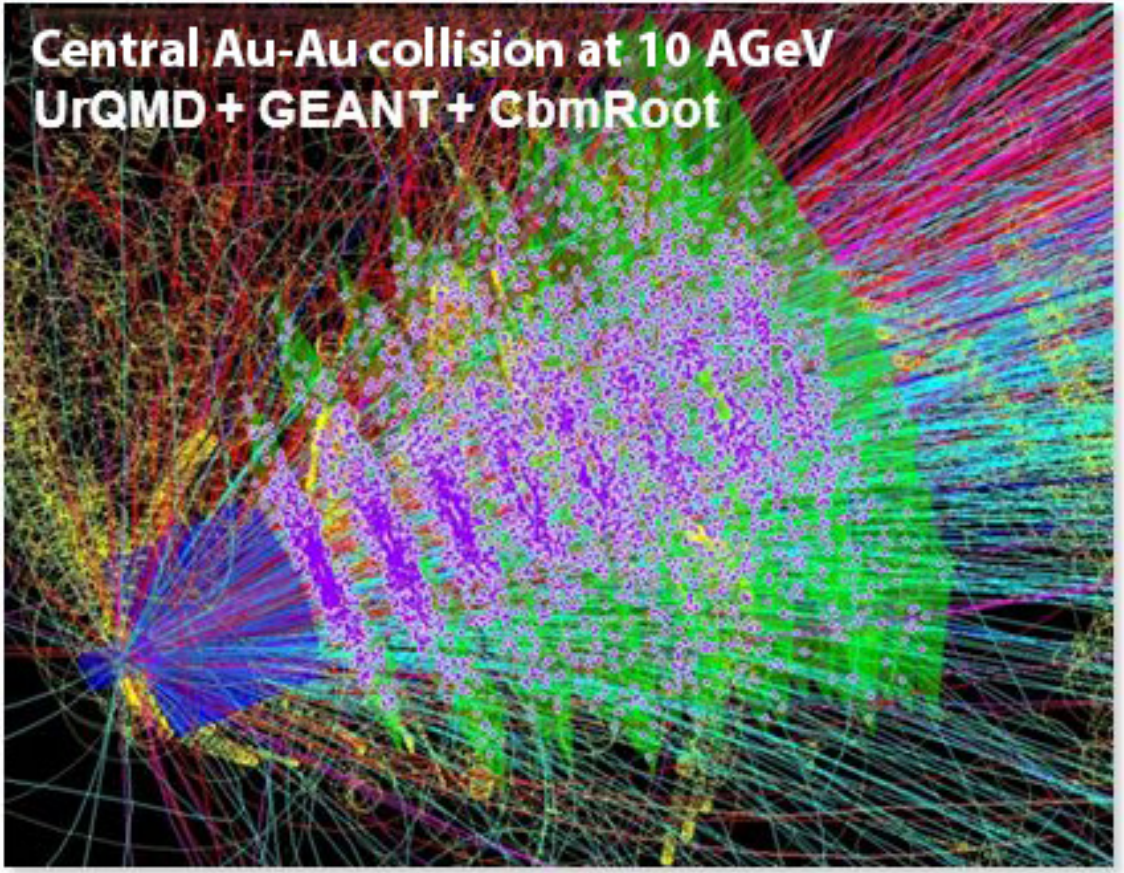
MAPS:

- CMOS sensors have low material budget
- Excellent spatial resolution
- Good time resolution
- Radiation tolerant

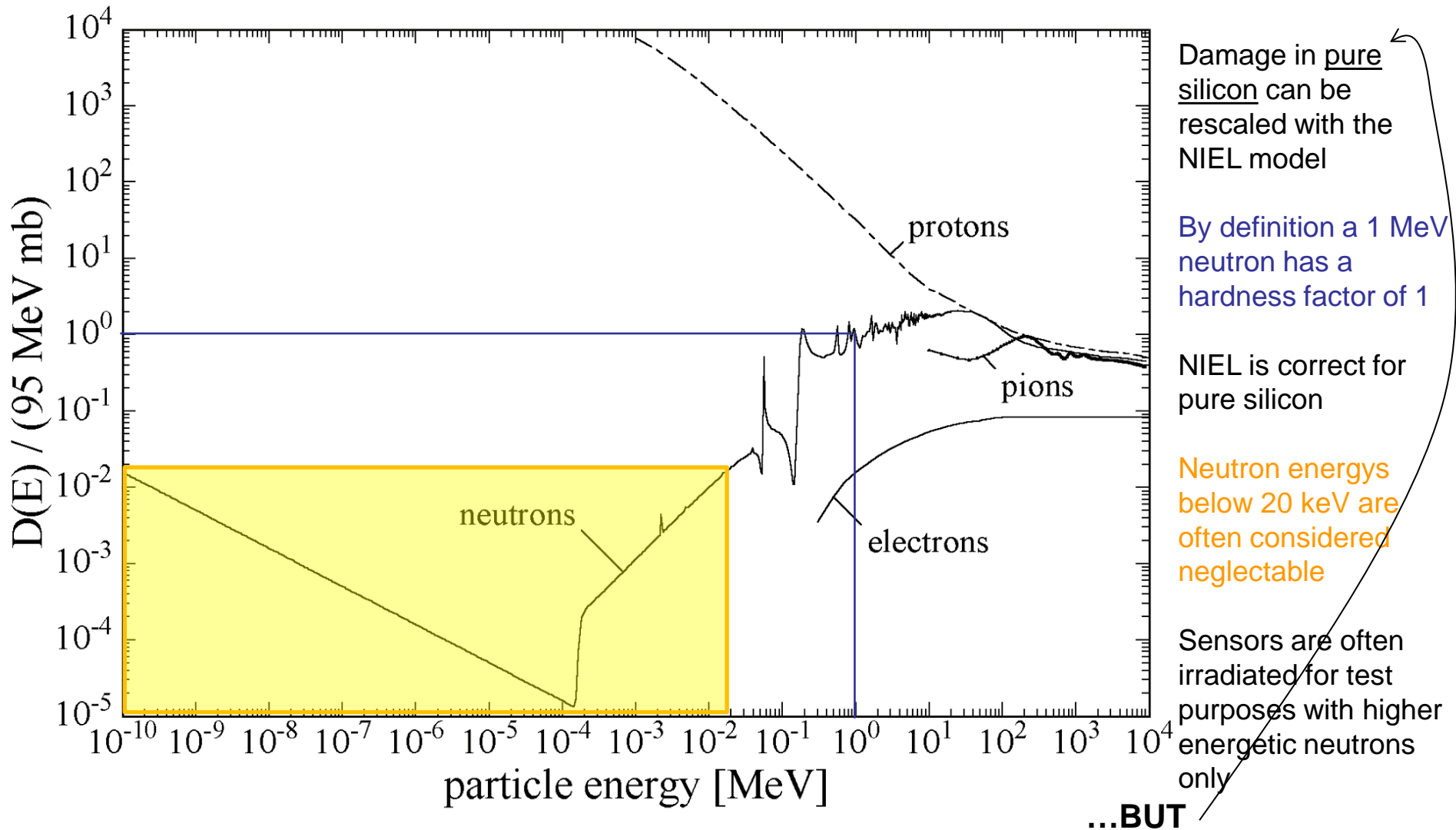




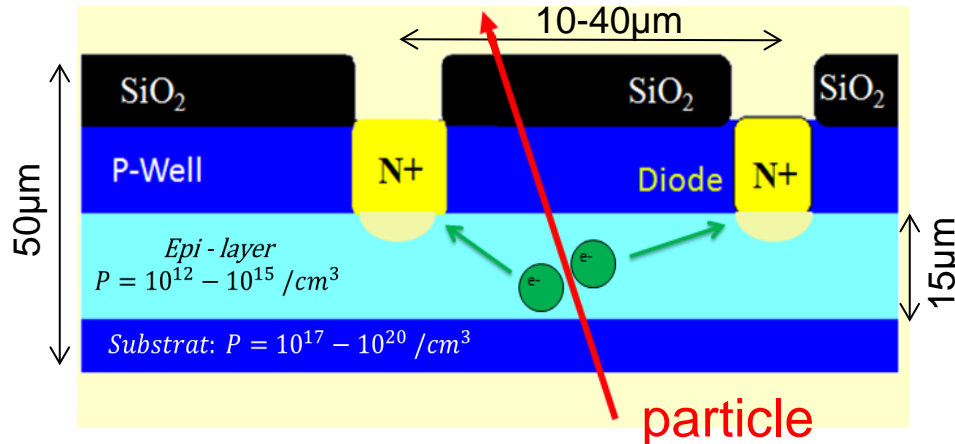
MVD  
(Micro Vert  
Detector)



# How do we test for radiation hardness?



# Is the NIEL hypothesis valid for P-doped sensors?

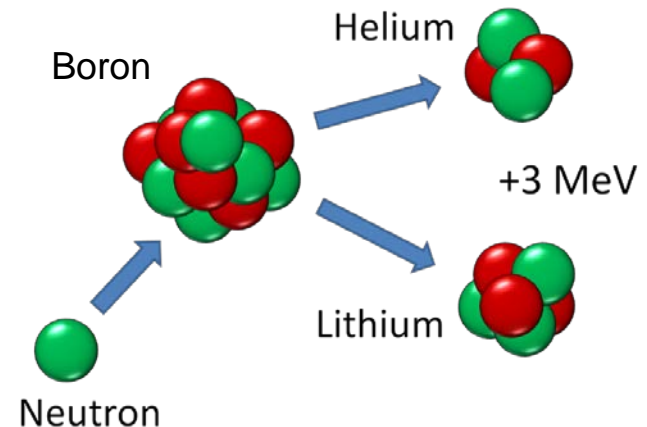


## CMOS Monolithic Active Pixel Sensors

- Are being optimized to tolerate extremely high radiation doses (ionizing and non-ionizing).
- Based typically on P-doped silicon  
=> Contains Boron

## Boron ( $^{10}\text{B}$ ) is known to:

- Capture thermal neutrons with huge cross section ( $\sim 1000$  b)
- Decay  $n + ^{10}\text{B} \Rightarrow ^7\text{Li} + ^4\text{He} + 3 \text{ MeV}$   
=> Fast ions are created in Si  
=> Additional bulk damage is created



Does  $^{10}\text{B}$  cause sizable additional radiation damage w.r.t standard NIEL model?

# Theoretical estimate

(Natural) Boron doping [ $1/\text{cm}^3$ ]

Neutron flux [ $\text{n}/\text{cm}^2$ ]

Energy dependent cross section

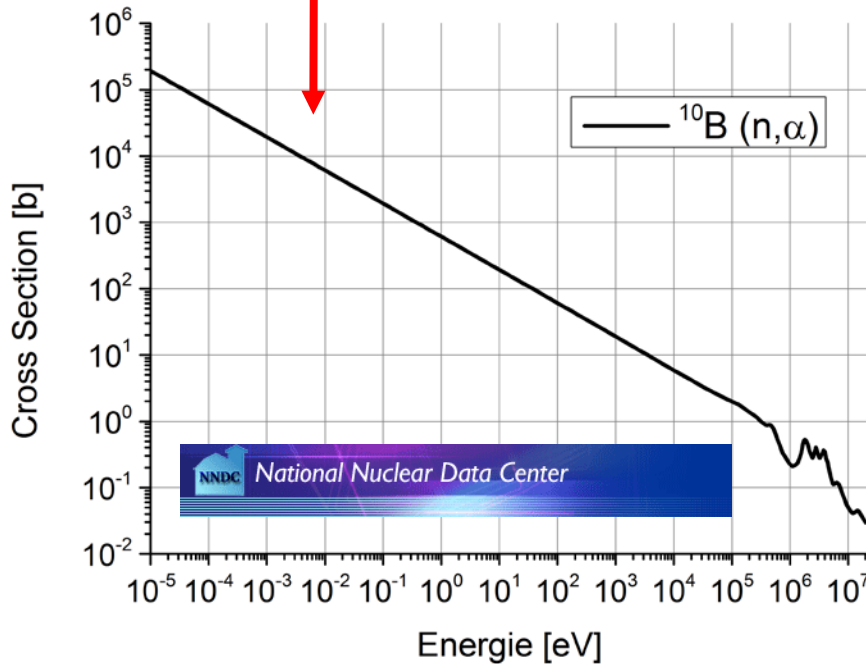
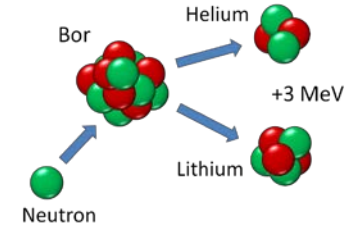
+

Boron decays [ $1/\text{cm}^3$ ]

Decay energy

+

Energy deposit [ $\text{J}/\text{cm}^3$ ]



Most energy deposit ionizing.  
How to get NIEL?

# From ion energy to NIEL

Idea: Compare number of vacancies:

- caused by fission ions (unknown hardness factor)
- caused by protons (known hardness factor)

Tool: SRIM (software and references: [www.srim.org](http://www.srim.org))

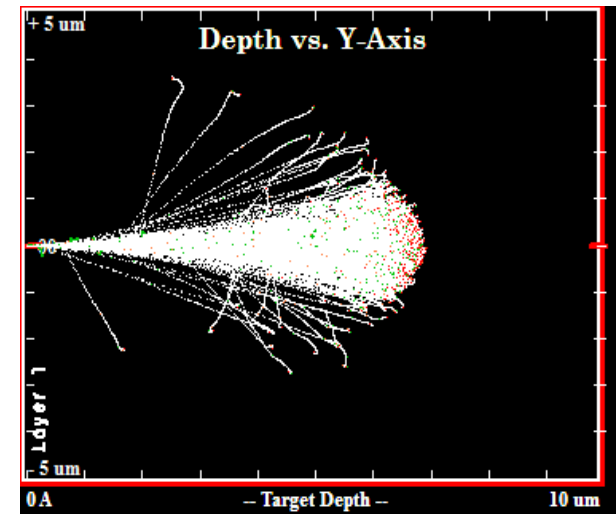
Simulates flight of ions in matter (~MeV energies)

⇒ Simulate vacancies cause by p,  $^4\text{He}$  and  $^7\text{Li}$

Results:

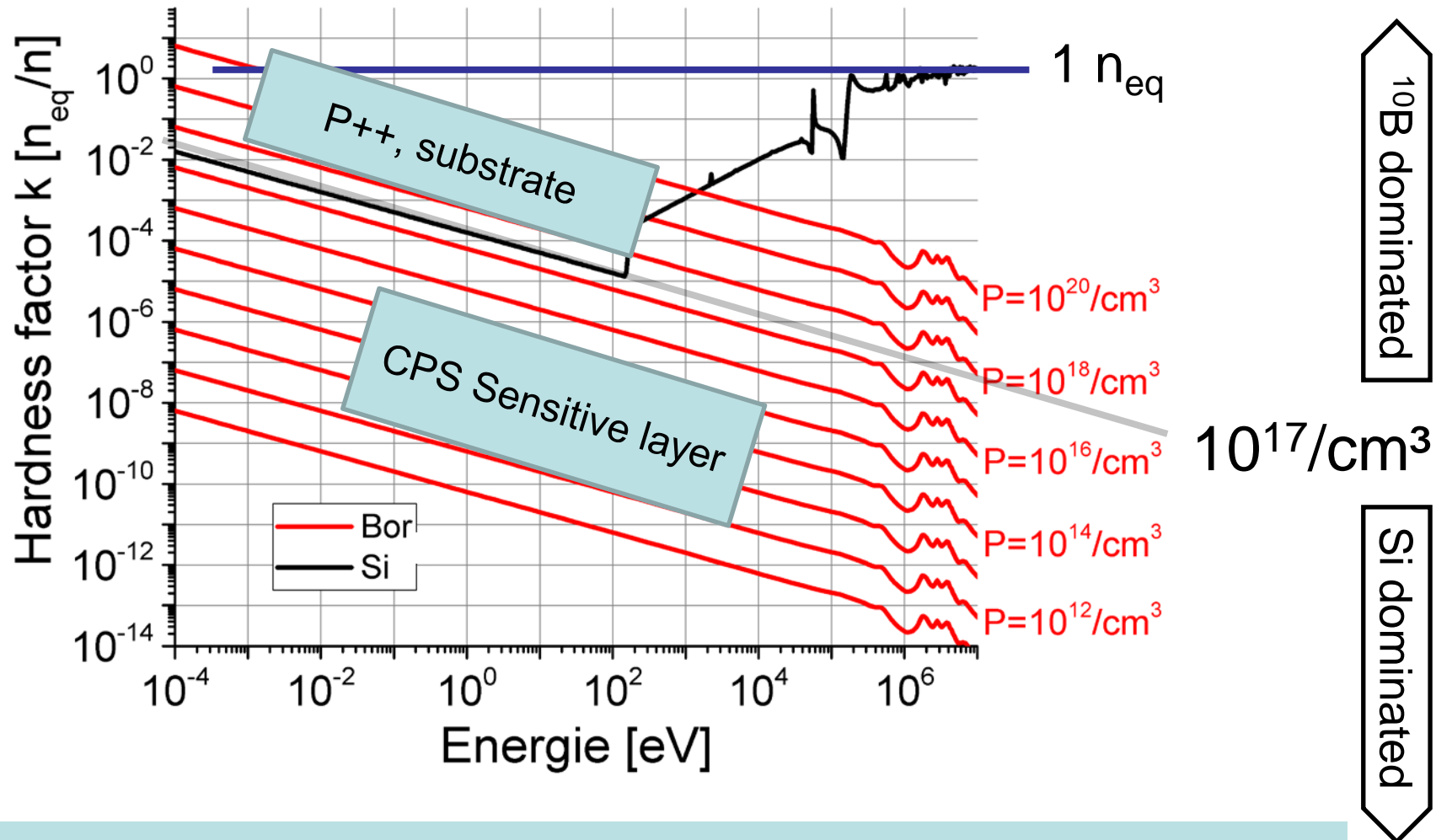
	Vacancies
p (30 MeV)	0.7 / 40 $\mu\text{m}$
$^4\text{He}$	277 / ion
$^7\text{Li}$	613 / ion

40 $\mu\text{m}$  Si target: Avoid energy loss  
=> const. hardness factor





# Result after normalization:



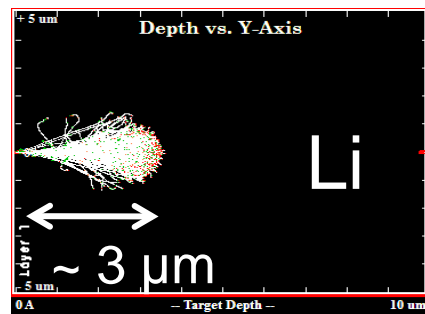
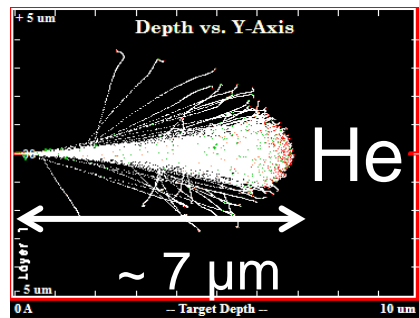
$^{10}B$  – fission => additional radiation damage in highly doped structures



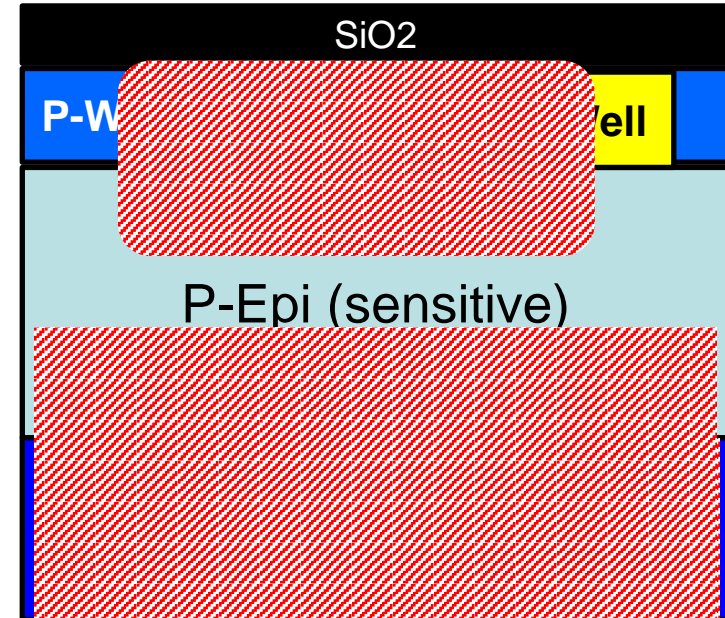
# Does boron decay additionally damage the sensor?

In first order:

- Lowly doped sensitive volume not affected
- Ions are created in highly doped volumes.



Penetration depth of ions (SRIM)



Possible damage mechanism:

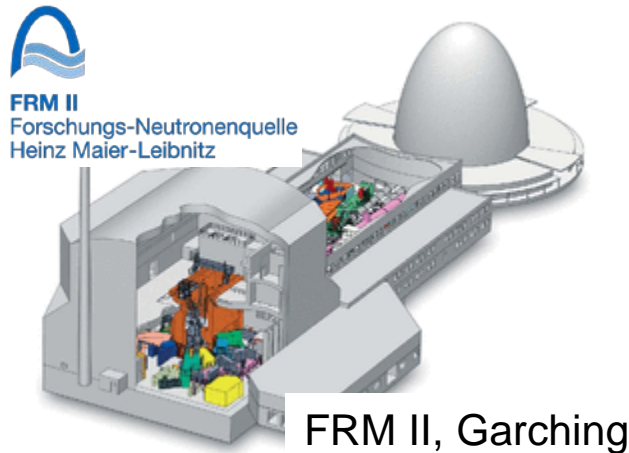
- Ions are created in P++
- Ions enter sensitive volume, create sizable (?) damage here

Likely:

- Only part of sensitive volume affected
- „Effective“ hardness factor depending on sensor geometry, etc...

# How do we test for additional damage?

Idea: Compare radiation damage caused by fast and cold neutrons

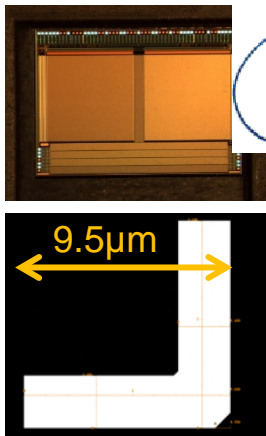


## MEDAPP

- Direct  $^{235}\text{U}$  fission neutrons
- 99% of all neutrons  $>100$  keV

## PGAA

- Cold neutrons  $1.8 \times 10^{-3}$  eV



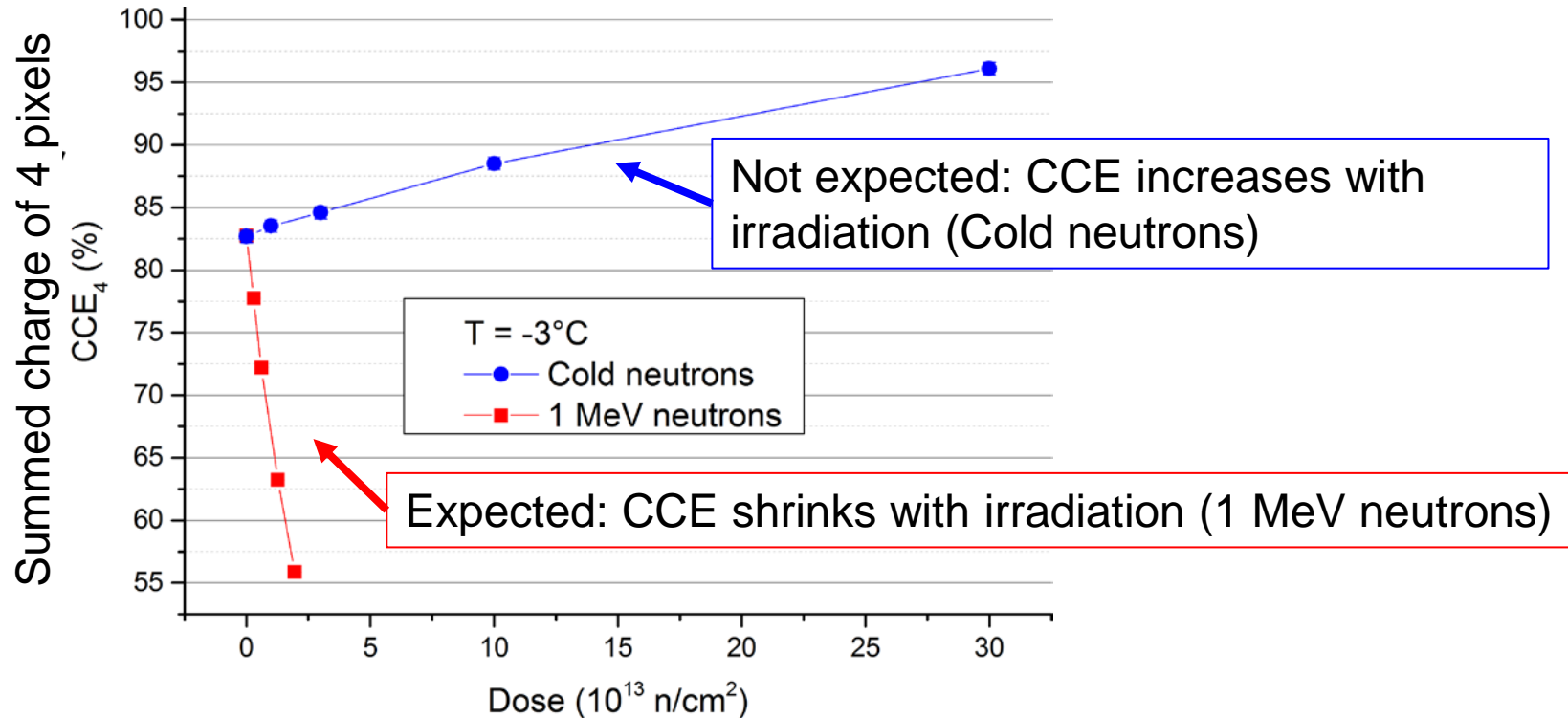
Sensor: MIMOSA-19, IPHC, Strasbourg

- Design: AMS 0.35 LR, Year 2006
- Pixel:  $12 \mu\text{m}$  pitch
- Doping assumption:  $\sim 10^{15}$  (*epi*),  $\sim 10^{19}$  (*substrate*)  
=> Not depleted, charge collection by diffusion

Observables: Charge collection efficiency

# What are our results on the additional damage?

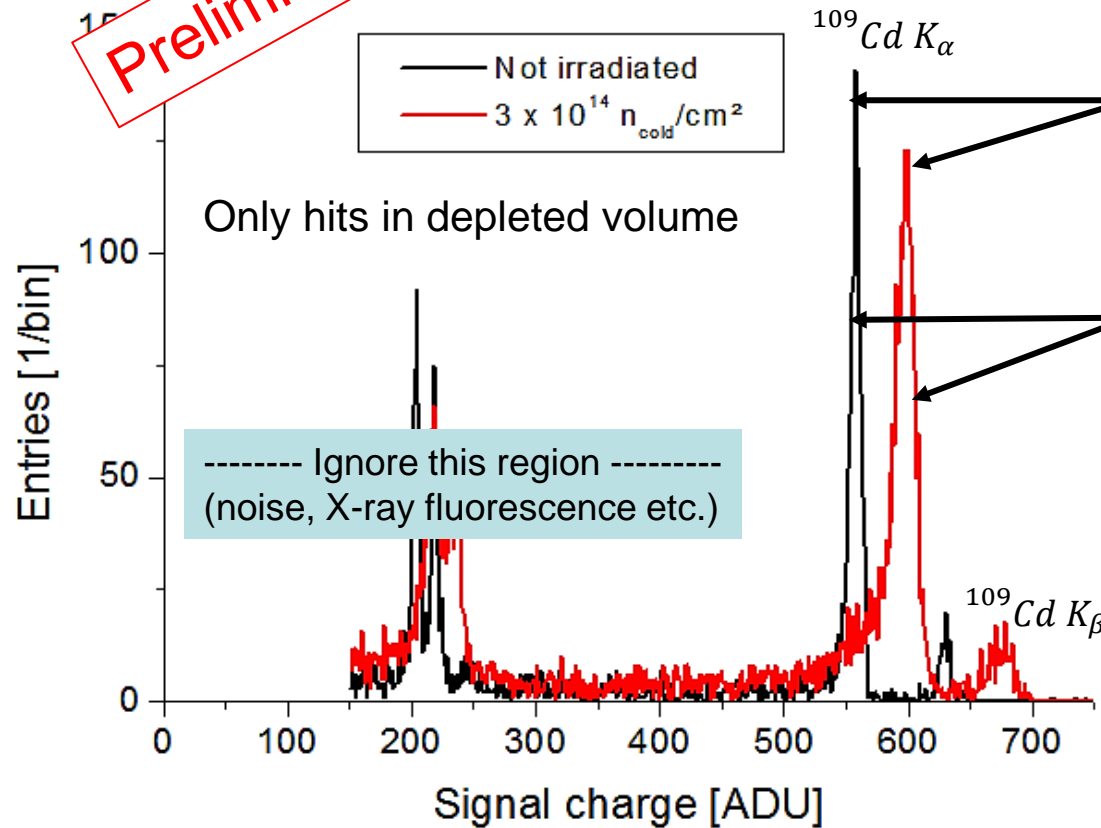
Sensor illuminated with  $^{109}\text{Cd}$  (22.1 keV X-ray), detect clusters



Response differs fundamentally between cold  $\Leftrightarrow$  1MeV Neutrons  
Effective hardness factor cannot be extracted

# Experimental results: CCE

**Preliminary!**



**G**ain increases after irradiation  
 ⇒ Decrease of diode capacity?  
 ⇒ More depletion?

**N**umber of entries increases after irradiation by factor x2.  
**S**cales with depleted volume  
 ⇒ More depletion!  
 ⇒ Less doping  
**A**brupt flat junction (?):  
 Doping decreases by factor x4

**P**otential explanation:

Intense acceptor removal (factor x4 from  $P=10^{15}/\text{cm}^3$ )

⇒ Additional depletion improves CCE, dominates trapping

! No significant acceptor removal observed with 1 MeV neutrons for  $<2 \times 10^{13} n_{\text{eq}}/\text{cm}^2$

# Summary and cautious conclusion

Does  $^{10}\text{B}$  fission cause sizable rad. damage in P-doped Si?

Theoretical estimate:

- $P > 10^{17}/\text{cm}^3 \Rightarrow$  Expect additional damage w.r.t standard NIEL curve
- Fission ions may damage lowly doped silicon indirectly due to  $7\mu\text{m}$  range

Experimental study (MIMOSA-19,  $\sim 10^{15}/\text{cm}^3$  epi layer,  $\sim 10^{19}/\text{cm}^3$  substrate ):

Observation:

CCE:

- Cold neutrons cause strong acceptor removal, CCE increases
- Acceptor removal exceeds finding for  $2 \times 10^{13} n_{\text{eq}}/\text{cm}^2$  (1MeV)

Preliminary conclusion:

- $^{10}\text{B}$  fission seems to cause rad. damage beyond standard NIEL
- Risk of unexpected effects in case of high thermal neutron doses.